

Durimide™ 8500-series

Photosensitive Polyimide Precursor

NMP-free, negative tone photosensitive polyimide formulation designed with a unique structure and sensitizer that gives it the following characteristics:

- · High photospeed
- Enhanced resolution
- · Wide process latitude
- Suitable for i-line, BB or LDI applications
- Self priming no external adhesion promotor required
- · Excellent adhesion
- High Tg

Superior mechanical property retention after extended pressure cooker test (> 1000 hour)

Cured film thickness range: 2 – 25+ µm

<u>Grade</u> <u>Viscosity</u> <u>Cured Film Thickness</u>

Durimide[™] 8505 1200 cSt $2-5 \mu m$ Durimide[™] 8510 3300 cSt $4-15 \mu m$ Durimide[™] 8520 6400 cSt $11-25+ \mu m$

Compatible Ancillary Products:

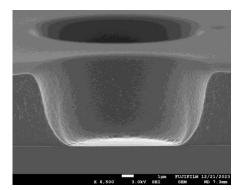
Developer/Rinse Combinations: HTR-D2 / RER 600

Back Side Rinse: HTR-D2 Edge Bead Remover: HTR-D2

Stripper Product: MS 3001 (NMP free)

8 9 10 12 1

Various size vias in a 12 µm softbake film, i-line stepper (404 nm Laser Microscope)



10 μm via in a 7 μm cured film (12 μm softbake film thickness), i-line stepper (SEM-image)

Typical cured film properties of Durimide™ 8500series (380°C/1h)

Tensile Strength	MPa	192
Young's Modulus	GPa	2.5
Tensile Elongation	%	80
Glass Transition Temperature	°C	313
Thermal Decomposition Temperature	°C	597
Coefficient of Thermal Expansion	ppm/°C	41

Durimide™ 8500-series process window

Silicon, SiO_xN_y, Substrate:*

SiC, epoxy, Al, Ag...

PI Thickness: 11 to 25+ µm Soft Bake: Depending film thickness range

100-110°C / 4-6 min

Exposure Tool: Mask aligner

Stepper BB i-line g-line h-line LDI 405 nm

Exp. Range: 90 - 300 mJ/cm² **Focus Range:** focus into film at

1/3rd film thickness

Post Exposure Delay: 30 min @ RT

Post Exposure Bake: 60 sec @ 50°C

Atomized spray, Dev. process:

continuous spray or

multiple puddle development

Developer/Overlap/ Rinse:

HTR-D2/RER 600

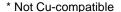
30"/10"/15"

Final cure conditions:

Cure temp: 350 to 420°C for 60 min

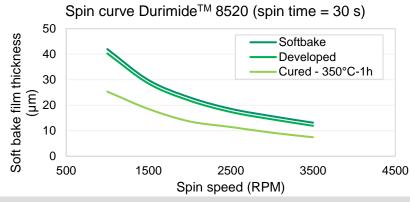
Descum:

Short O₂-plasma



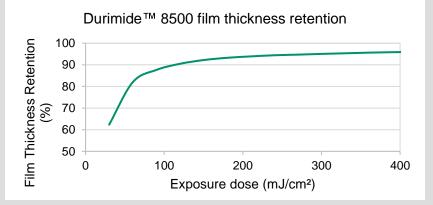
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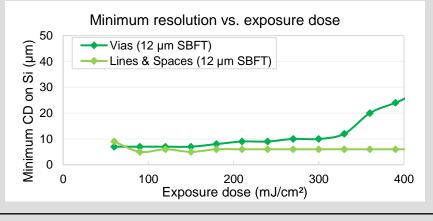
Please refer to the material safety data sheet (MSDS) for complete information on storage and handling, toxicological properties, personal protective equipment, first aid, spill and leak procedures, and waste disposal. To order an MSDS, call your FFEM sales office. Before using or handling this product, review the MSDS information thoroughly.



Recommended spin time is 30-60 seconds. Film thickness can be varied by changing the spin-time and spin-speed.

Durimide[™] 8500 undergoes a shrinkage of approx. 45% from soft bake to cure.





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